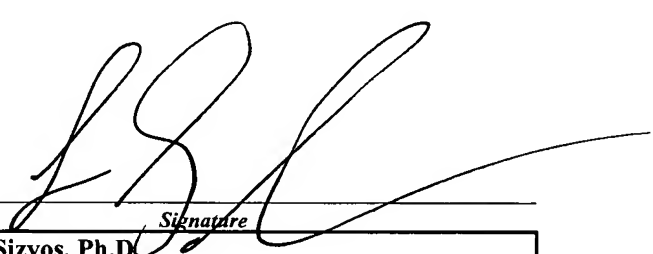
**TRANSMITTAL OF FORMAL DRAWINGS**Docket No.  
**YOR920030138US1 (16603)**In this Application Of: **Stephen W. Bedell, et al.**

Serial No.	Filing Date	Confirmation No.	Examiner	Art Unit
10/654,232	9/3/2003		Unassigned	Unassigned

Invention: **USE OF THIN SOI TO INHIBIT RELAXATION OF SiGe LAYERS**Address to:  
**Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450**

Transmitted herewith are:

5 sheets of formal drawing(s) for this application.

☒ Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).  
*Signature*  
**Leslie S. Sizvos, Ph.D.  
Registration No. 39,394  
SCULLY, SCOTT, MURPHY & PRESSER  
400 Garden City Plaza  
Garden City, New York 11530  
(516) 742-4343**Dated: **December 1, 2003****I certify that this document and attached formal drawings  
are being deposited on 12/1/2003 with the  
U.S. Postal Service as first class mail under 37 C.F.R. 1.8  
and addressed to the Commissioner for Patents, P.O. Box  
1450, Alexandria, VA 22313-1450.**  
*Signature of Person Mailing Correspondence***Leslie S. Sizvos, Ph.D.***Typed or Printed Name of Person Mailing Correspondence*